L	Hits	Search Text	DB	Time stamp
Number				
1	35	<pre>(collar with nitride with \$20xide) and ((deep adj1 trench) same (shallow adj1 trench)) and ((hard adj1 mask) hardmask photoresist mask).bi.</pre>	USPAT	2004/02/03
2	19	1 -	USPAT	2004/02/03
3	14		USPAT	2004/02/03
_	7	(yan-jiang shum-danny-pak-chum).in.	USPAT; US-PGPUB; EPO; DERWENT	2004/01/29 11:02
-	1	"20040005753"	USPAT; US-PGPUB	2004/01/23
-	1	("6355106").PN.	USPAT	2004/01/23
-	1241	(self adj1 align\$3) same (isolation STI) same (trench opening recess).bi.	USPAT	2004/01/29
-	436		USPAT	2004/02/03
-	1		USPAT	2004/01/29 12:52